



Datasheet

SE50A-ECO 200SS FT-IR Metrology Tool

For Material Characterization

Systems Engineering combines the Thermo Fisher Scientific FT-IR measurement technology and JEL's Sorter System to introduce a new generation

"FT-IR SE-50 series" semiconductor material characterization tools.

Application Specifications

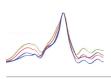




Carbon & Oxygen in Silicon

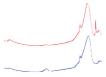
	Carbon	Oxygen [*]
Range	► 0.1 to 10ppmA	▶ 0.3 to 35 ppmA
Precision	►STD 0.05 ppmA	► STD0.08 ppmA

*All carbon and oxygen values reported using ASTM 1979 calculations.



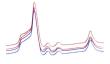
Boron & Phosphorus

	Boron	Phosphorus
Range	► 1 - 10 Wt%	► 2 - 12 Wt%
Precision	► ± 0.05 Wt%	► ± 0.05 Wt%



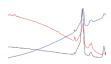
Hydrogen in Silicon Nitride

	Si-H	N-H
Range	► 3 - 30 Atom%	▶ 3 - 30 Atom%
Precision	► ± 0.3 Atom%	► ± 0.3 Atom%



Fluorine in SiO₂ Films

Thickness ► 3000 - 10000Å
Fluorine Concentration ► STD< 0.2 Fwt%

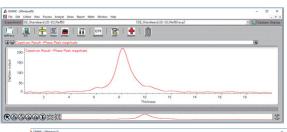


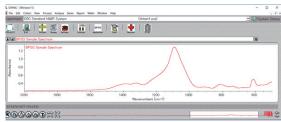
Carbon-doped Films

Silicon Nitride Silicon Oxide



Operation Software





- Intuitive Graphical User Interface
- Easy-to-Use operator and Authorized engineer user levels
- Easy to learn and use, giving optimum efficiency
- Measurement result, display and data logging.





Specifications

RELIABILITY	
MTBF	> 6 months
MTTR	48 hours
MTTS	4 hours
Uptime	> 97%

Computer Specifications		
Operation	Windows 10 64bit Memory 32GB	
System		
	Hard Disk	SSD RAID1

OPTICAL	
Spectral Range	7800 - 350cm ⁻¹
Spectral Resolution	0.5cm ⁻¹
Beam Diameter	Standard 8mm (Variable)
Analysis Angle	15°

FACILITY REQUREMENTS		
Power		100 - 240V
		(50/60Hz)
House Vacuum		-61±10kPa (G)
		30L/min (ANG)
Pressurized Gas	CDA	none
	N ₂	0.2MPa (G)
		15L/min (ANR)



SE50 Product Line

Hardware				
Product#	Model	Wafer size	Station	Handring
ECO-02S	SE50S-ECO	2-12 inch	Stage	Edge Grip
ECO-031	SE50A-ECO_150SS	2-6 inch	Single	Vacuum
ECO-032	SE50A-ECO_150DS	2-6 inch	Double	Vacuum
ECO-041	SE50A-ECO_200SS	4-8 inch	Single	Vacuum
ECO-042	SE50A-ECO_200DS	4-8 inch	Double	Vacuum
ECO-043D	SE50A-ECO_200DSMIF	8 inch	Double SMIF	Vacuum
ECO-044	SE50A-ECO_200FS	4-8 inch	Four	Vacuum
ECO-051	SE50A-ECO_300SS	8-12 inch	Single	Vacuum
ECO-052	SE50A-ECO_300DS	8-12 inch	Double	Vacuum
ECO-051F	SE50A-ECO_300SF	8-12 inch	Single Foup	Vacuum
ECO-052F	SE50A-ECO_300DF	8-12 inch	Double Foup	Vacuum
ECO-051E	SE50A-ECO_300SSE	12 inch	Single	Edge Grip
ECO-052E	SE50A-ECO_300DSE	12 inch	Double	Edge Grip
ECO-051FE	SE50A-ECO_300SFE	12 inch	Single Foup	Edge Grip
ECO-052FE	SE50A-ECO_300DFE	12 inch	Double Foup	Edge Grip
THZ-02	SE50A-THZ_150SiSD	4-6 inch	Double	Vacuum
THZ-04	SE50A-THZ_150SiSF	4-6 inch	Four	Vacuum
THZ-06	SE50A-THZ_150SiSS	4-6 inch	Six	Vacuum

Software	
Product#	Model
ECO-1EP	Epitaxial Thickness
ECO-1CO	Carbon & Oxygen in Silicon
ECO-1BP	Boron & Phosphorus in BPSG or PSG Films
ECO-1SN	Hydrogen in Silicon Nitride
ECO-1SF	Fluorine in Silicon Oxside Films
ECO-1MB	Multi Background Option
ECO-1GM	GEM/SECS Host Communication
ECO-1SH	Share File Host Communication
ECO-1DS	Double Station Sorting Support
ECO-1FS	Four Station Sorting Support
ECO-1SS	Six Station Sorting Support
ECO-1OH	Hydrogen in Silicon Software
ECO-1SC	SiC Epitaxial Thickness Support
ECO-1SU	Shuttle Background Software
ECO-1CH	Carbon-doped Films
ECO-1SO	Silicon Oxiside Film Analysis (SiXx)
Ontion	

Option	
Product#	Model
ECO-FA1	200mm wafer adapter for FOUP system
ECO-FA2	Tag Reader for FOUP & SMIF system • Keyence : BL600 • Omron : V640
ECO-FA3	E84 OHT Support for OHT COM module
ECO-FA4	Safety Light Curtain for OHT
ECO-FA5	Sensing Ionizer System
ECO-FA6	Water ID Reader Module
ECO-FA7	Optical FFU (Fan Filter Unit)
ECO-FA8	Share File Host Communication



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Made in Japan